



RE 02
9/12/98
GP- 2816

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

the application of:

John Mark Anthony *et al.*
Serial No.: 09/116,138
Filed: 07/15/98
For: High Permittivity Silicate Gate Dielectric

Docket: TI-24953
Examiner: TBD
Art Unit: 2816

#5
4/27/98
M. Fudge

INFORMATION DISCLOSURE STATEMENT

September 9, 1998

Assistant Commissioner For Patents
Washington, D. C. 20231

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| MAILING CERTIFICATE UNDER 37 CFR § 1.8 | |
| I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Assistant Commissioner for Patents, Washington, DC 20231 on | |
| <u>September 10</u> , 1998. | |
| Sue Short | |

Examiner:

Applicants wish to bring to the attention of the Patent and Trademark Office the information noted on the enclosed PTO-1449.

Copies of reference(s) AP and AQ are not enclosed as these are pending applications. Applicants believe that no fee is due. However, the Commissioner is authorized to charge any necessary fee to Deposit Account 20-0668.

Respectfully submitted,

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